

EAST Search History

EAST Search History (Prior Art)

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L10	5265	subramanian.in.	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2011/03/23 15:32
L12	3383	(electroform\$4 electro?form\$4 electroplat\$4 electro?plat\$4 electroly\$3 plated plating anodiz\$3) with (nickel copper cupronickel Cu Ni) with (mask\$3 resist etch?stop etching?stop photoresist\$3 photo?resist\$3 (protect\$4 near\$4 (coat\$4 layer\$4 film))) with (groove recess hole depression trench channel tunnel slot slit)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2011/03/23 16:22
L13	24440	(electroform\$4 electro?form\$4 electroplat\$4 electro?plat\$4 electroly\$3 plated plating anodiz\$3) same (mask\$3 resist etch?stop etching?stop photoresist\$3 photo?resist\$3 (protect\$4 near\$4 (coat\$4 layer\$4 film))) same (metal metall\$4 conduct\$4 nickel copper cupronickel Cu Ni) same (groove recess hole depression trench channel tunnel slot slit)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2011/03/23 16:23
L14	3110	205/67-79.cds.	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2011/03/23 17:29
L15	208	14 and (electroform\$4 electro?form\$4 electroplat\$4 electro?plat\$4 electroly\$3 plated plating anodiz\$3) same (mask\$3 resist etch?stop etching?stop photoresist\$3 photo?resist\$3 (protect\$4 near\$4 (coat\$4 layer\$4 film))) same (metal metall\$4 conduct\$4 nickel copper cupronickel Cu Ni) same (groove recess hole depression trench channel tunnel slot slit)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2011/03/23 17:29

L16	4	("20030026697" "20080246558").PN.	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2011/03/23 17:31
S1	4	("2003026697").PN.	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2011/03/23 13:39
S2	2	("20030026697").PN.	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2011/03/23 13:39
S3	9	("2003/0026697").URPN.	USPAT	OR	ON	2011/03/23 13:45
S4	157411	(electroform\$4 electro?form\$4 electroplat\$4 electro?plat\$4 electrol\$4 plated plating anodiz\$3) and (mask\$3 resist etch? stop etching?stop photoresist\$3 photo?resist\$3 (protect\$4 near4 (coat\$4 layer\$4 film))) and (metal metall\$4 conduct\$4 nickel copper cupronickel Cu Ni) and (groove recess hole depression trench channel tunnel slot slit)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2011/03/23 14:06
S5	24686	(electroform\$4 electro?form\$4 electroplat\$4 electro?plat\$4 electrol\$4 plated plating anodiz\$3) same (mask\$3 resist etch? stop etching?stop photoresist\$3 photo?resist\$3 (protect\$4 near4 (coat\$4 layer\$4 film))) same (metal metall\$4 conduct\$4 nickel copper cupronickel Cu Ni) same (groove recess hole depression trench channel tunnel slot slit)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2011/03/23 14:07
S6	1359	(29/527.2).CCLS.	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2011/03/23 14:09

S7	14372	(29/527.1,890.09,890.1,825,829,830,592.1).CCLS.	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2011/03/23 14:09
S8	4444	(427/457,58,99.5,105).CCLS.	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2011/03/23 14:10
S9	1441	(204/450,471,485).CCLS.	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2011/03/23 14:10
S10	12136	(electroform\$4 electro?form\$4 electroplat\$4 electro?plat\$4 electrol\$4 plated plating anodiz\$3) with (metal metall\$4 conduct\$4 nickel copper cupronickel Cu Ni) same (mask\$3 resist etch?stop etching?stop photoresist\$3 photo?resist\$3 (protect\$4 near4 (coat\$4 layer\$4 film))) with (groove recess hole depression trench channel tunnel slot slit)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2011/03/23 14:11
S11	6535	(electroform\$4 electro?form\$4 electroplat\$4 electro?plat\$4 electrol\$4 plated plating anodiz\$3) with (metal metall\$4 conduct\$4 nickel copper cupronickel Cu Ni) with (mask\$3 resist etch?stop etching?stop photoresist\$3 photo?resist\$3 (protect\$4 near4 (coat\$4 layer\$4 film))) with (groove recess hole depression trench channel tunnel slot slit)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2011/03/23 14:11
S12	3428	(electroform\$4 electro?form\$4 electroplat\$4 electro?plat\$4 electrol\$4 plated plating anodiz\$3) with (nickel copper cupronickel Cu Ni) with (mask\$3 resist etch?stop etching?stop photoresist\$3 photo?resist\$3 (protect\$4 near4 (coat\$4 layer\$4 film))) with (groove recess hole depression trench channel tunnel slot slit)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2011/03/23 14:12

S13	21436	S6 S7 S8 S9	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2011/03/23 14:22
S14	930	S5 and S13	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2011/03/23 14:22
S15	872	S14 and (polish\$3 grind\$3 sand\$3 abra\$4 fil\$3 mill\$3 machin \$3 CMP burnish\$3)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2011/03/23 14:27
S16	2	("6602053").PN.	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2011/03/23 14:34
S17	36	("2641439" "20020141872" "3678570" "3806276" "4528048" "4623087" "4629397" "4769309" "5640767" "5875549" "6203927" "6018950" "6149160").PN.	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2011/03/23 14:37

EAST Search History (Interference)

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3/ 23/ 2011 5:51:42 PM

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